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LIST OF PATENTS AND PUBLICATIONS APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Form PTO-1449)

Page 1 of 2 Attorney Docket: 101769-311-

Applicants: Marc HUSEMANN, et al.

Filing Date: Herewith (International Filing Date November 11, 2003)

Group: TBA

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EXAMINER: Initial if Reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformation and not considered, include copy of this form with next communication to applicant.

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- *2 Equivalent to US 5,602,221
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